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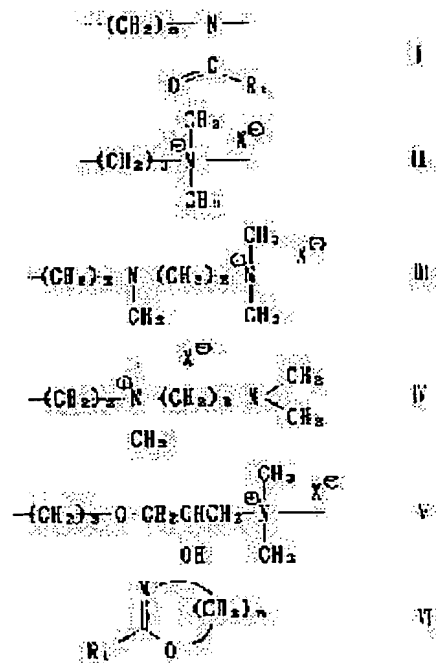
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(54) COSMETIC

(57)Abstract:

PURPOSE: To obtain cosmetic capable of exhibiting natural gloss, smoothness, softness, good combing property, water repellency and hair protecting effect of hair after treatment and water repellency of skin and skin-protecting effect.

CONSTITUTION: The objective cosmetic containing a poly(N-acylalkyleneimine)- modified silicone having (A) a segment of a poly(N-acylalkyleneimine) having recurring units of formula I [R1 is H, 1-22C alkyl, cycloalkyl, aralkyl or aryl; (n) is 2 or 3] and (B) a segment of an organopolysiloxane in the molecule and binding the segment A through a group partially having a structure of quaternary ammonium. e.g. a group of formula II to formula V to the terminal and/or side chain of the segment B and being 1/20 to 20/1, preferably 1/10 to 5/1 in weight ratio of the segment A and segment B, having 500-500000, preferably 1000-100000 molecular weight. The segment A is obtained by subjecting a cyclic imino ether compound of formula VI to ring opening and its molecular weight is preferably in the range of 500-10000.



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